## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

re Appln. of: Kenichi Mitsumori ET AL.

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For: ULTRASONIC VIBRATOR,

WET-TREATMENT NOZZLE,

AND WET-TREATMENT APPARATUS

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Examiner: Not yet assigned

1746

Art Unit:

## INFORMATION DISCLOSURE STATEMENT

In accordance with the duty of disclosure under 37 C.F.R. §1.56 and §§1.97-1.98, and more particularly in accordance with 37 C.F.R. §1.97(b), Applicants hereby cite the following reference(s):

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